MAR 2 1 2005

Patent Docket No.: TRAN-P283

Info@mation Disclosure Statement Transmittal

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First Class	Postage and ac	dressed to the Commiss	sioner of P	atents, P. O. B	ox 1450, Alexandria, VA 2231	3-1450, on the below-date	e of deposit.
Date of	03/15/05	Name of Person	Donna	Petford	Signature of the Person	16 , 0 10	-6.0
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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Inventor(s):

Eric Chen-Li SHENG, David HOFFMAN, John Laurence NIVEN

Application No.:

10/791,099

Group Art Unit:

Filed:

03/01/04

Examiner:

Title:

SYSTEM AND METHOD FOR REDUCING TEMPERATURE VARIATION DURING

BURN-IN

Commissioner of Patents P. O. Box 1450 Alexandria, VA 22313-1450

Sir:

Information Disclosure Statement Transmittal

Tran	smitted herewith is the following:
	Formal drawings, totaling sheets.
	Informal drawings, totaling sheets.
	Certification for PTO Consideration
	Information Disclosure statement (_2_ sheets)
	Information Disclosure statement and late filing fee
	Form 1449
**********	Petition for Extension of Time
*********	Other:
*********	***************************************

Fee Calculation (for other than a small entity)						
Fee Items	Fee Rate	Total				
Petition for Extension of Time (fee calculated elsewhere	\$.00	0.00				
Information Disclosure Statement, late filing	\$180.00	0.00				
Other:						
Total Fees		0.00				

PAYMENT OF FEES

- 1. The full fee due in connection with this communication is provided as follows:
- [X] The Commissioner is hereby authorized to charge any additional fees associated with this communication or credit any overpayment to Deposit Account No.: 23-0085.

 A duplicate copy of this authorization is enclosed.
- [] A check in the amount of \$\sumset\$
- [] Charge any fees required or credit any overpayments associated with this filing to Deposit Account No.: 23-0085.

Please direct all correspondence concerning the above-identified application to the following address:

WAGNER, MURABITO & HAO LLP Two North Market Street, Third Floor San Jose, California 95113 (408) 938-9060

Customer No: 000041066

Respectfully submitted,

Anthony C. Murabito Reg. No. 35,295



HE UNITED STATES PATENT AND TRADEMARK OFFICE

Attorney Docket No.: TRAN-P283

Inventor(s):

Eric Chen-Li SHENG, David HOFFMAN, John Laurence NIVEN

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SYSTEM AND METHOD FOR REDUCING TEMPERATURE VARIATION DURING

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P. O. Box 1450

Alexandria, VA 22313-1450

Sir:

Information Disclosure Statement Submitted Pursuant to 37 C.F.R. 1.97(b)

The citations referenced herein, copies attached, may be material to the examination of the above-identified application and are, therefore, submitted in compliance with the duty of disclosure as defined in 37 C.F.R. 1.56. The Examiner is requested to make these citations of official record in the application.

This Information Disclosure Statement submitted in accordance with 37 C.F.R. 1.97(b) is not to be construed as a representation that a search has been made, that additional items material to the examination of this application do not exist, or that any one or more of these citations constitute prior art under 35 U.S.C. 102.

The Examiner's attention is respectfully directed to the following U.S. Patents:

Pat. No. 5,119,337	Pat. Title SEMICONDUCTOR MEMORY DEVICE HAVING BURN-IN TEST FUNCTION	Grant Date 06/02/92
5,406,212	BURN-IN APPARATUS AND METHOD FOR SELF- HEATING SEMICONDUCTOR DEVICES HAVING BUILT IN TEMPERATURE SENSORS	
5,844,429	BURN-IN SENSING CIRCUIT	12/01/98
6,037,792	BURN-IN STRESS TEST MODE	03/14/00
6,100,751	FORWARD BODY BIASED FIELD EFFECT TRANSISTOR PROVIDING DECOUPLING CAPACITANCE	08/08/00
6,104,061	MEMORY CELL WITH VERTICAL TRANSISTOR AND BURIED WORD AND BODY LINES	08/15/00
6,114,866	SEMICONDUCTOR DEVICE TEST BOARD AND METHOD FOR EVALUATING SEMICONDUCTOR DEVI	09/05/00 CES
6,157,201	BURN-IN SYSTEM FOR RELIABLE INTEGRATED CIRCUIT MANUFACTURING	12/05/00
6,137,301	EPROM USED AS A VOLTAGE MONITOR FOR SEMICONDUCTOR BUR-IN	10/24/00

rev 6/07 inv

6,218,892	DIFFERENTIAL CIRCUITS EMPLOYING FORWARD BODY BIAS	04/17/01
6,262,588	BIAS MONITOR FOR SEMICONDUCTOR BURN-IN	07/17/01
6,310,485	INTEGRATED CIRCUIT DEVICE HAVING A BURN-IN MODE FOR WHICH ENTRY INTO AND EXIT FROM CAN BE CONTROLLED	10/30/01

Please direct all correspondence concerning the above-identified application to the following address:

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Respectfully submitted,

Anthony C. Murabito Reg. No. 35,295



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Attorney Docket No.: TRAN-P283

Inventor(s): Eric Chen-Li SHENG, David HOFFMAN, John Laurence NIVEN

Application No.: 10/791,099 Group Art Unit:

Filed: 03/01/04 Examiner:

Title: SYSTEM AND METHOD FOR REDUCING TEMPERATURE VARIATION DURING

BURN-IN

Form 1449

U.S. Patent Documents

Examiner						Sub-	Filing
Initial	No.	Patent No.	Date	Patentee	Class	class	Date
	Α	5,119,337	06/02/92	Shimizu et al.	365	201	04/16/90
	В	5,406,212	04/11/95	Hashinaga et al.	324	760	07/17/92
	С	5,844,429	12/1/98	Cho	327	68	07/15/96
	D	6,037,792	03/14/00	McClure	324	760	12/21/96
	E	6,100,751	08/08/00	De et al.	327	534	05/13/98
	F	6,104,061	08/15/00	Forbes et al.	257	330	02/27/98
	G	6,114,866	09/05/00	Matsuo et al.	324	760	02/04/98
	Н	6,157,201	12/05/00	Leung, Jr.	324	760	01/28/98
	1	6,137,301	10/24/00	Chen	324	760	05/11/98
	J	6,218,892	04/17/01	Soumyanath et al.	327	537	02/24/99
	K	6,262,588	07/17/01	Chen	324	765	08/07/00
	Ļ	6,310,485	10/30/01	McClure	324	760	01/27/00
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Foreign Patent or Published Foreign Patent Application

Examiner		Document	Publication	Country or		Sub-	Trans	slation
Initial	No.	No.	Date	Patent Office	Class	class	Yes	No
	N	l						
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Other Documents

Examiner Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication
	Т	
Examiner		Date Considered

Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.